



# Zernike-type phase contrast X-ray microscopy at 4 keV Photon energy with 60 nm resolution

Ulrich Neuhausler (ESRF, Grenoble, France)

Gerd Schneider (BESSY, Berlin, Germany)

Collaborators:

Erik Anderson, Bruce Harteneck (CXRO, LBL, Berkeley, CA, U.S.A.)

Wolfgang Ludwig (ESRF), Dirk Hambach (IRP, Universität Göttingen, Germany)

Acknowledgements:

Bob Baker, Jean Susini, Remi Tucoulou, Sylvain Laboure,  
Eric Gagliardini, Gilles Berruyer, Franck Demarcq (ESRF)

# Outline

**Introduction:** The ID 21 X-ray microscopes (using Fresnel zone plates):

- scanning X-ray microscope (SXM), 2 – 8 keV, elemental mapping of medium Z elements and chemical analysis (XANES) by fluorescence
- full-field transmission X-ray microscope (TXM), 4 keV, high-resolution imaging, phase contrast

**Principle of Zernike phase contrast**

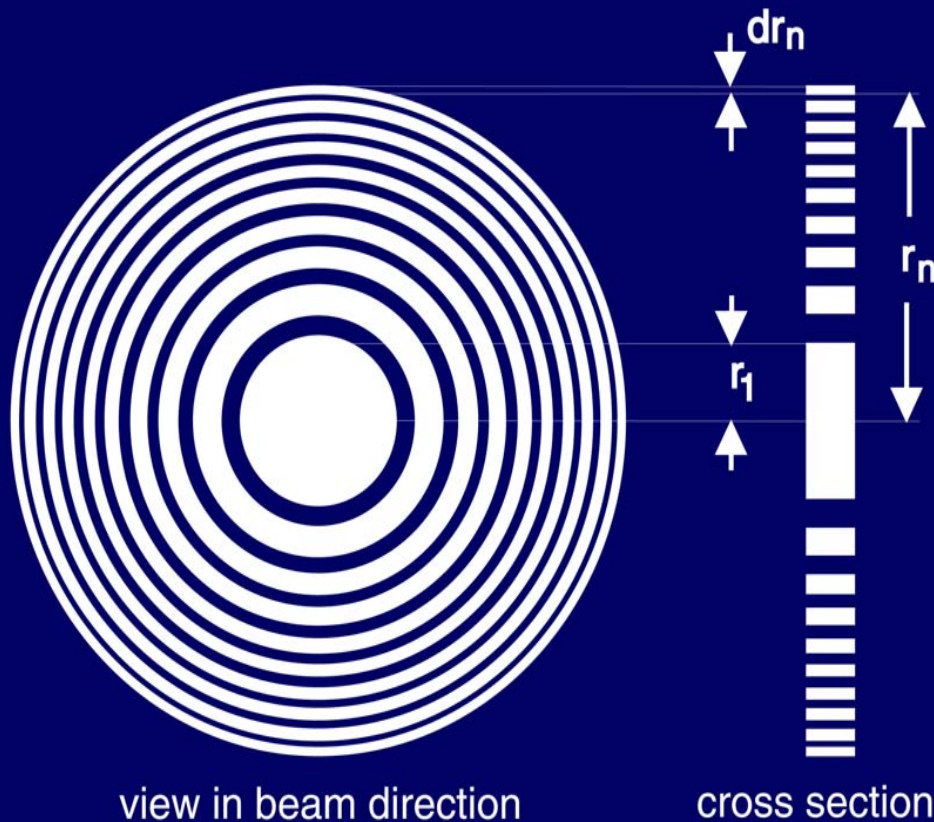
**Application examples**

Zernike phase contrast X-ray microscopy on microelectronics samples

- SEMATECH serpentine resistor
- AMD microprocessor

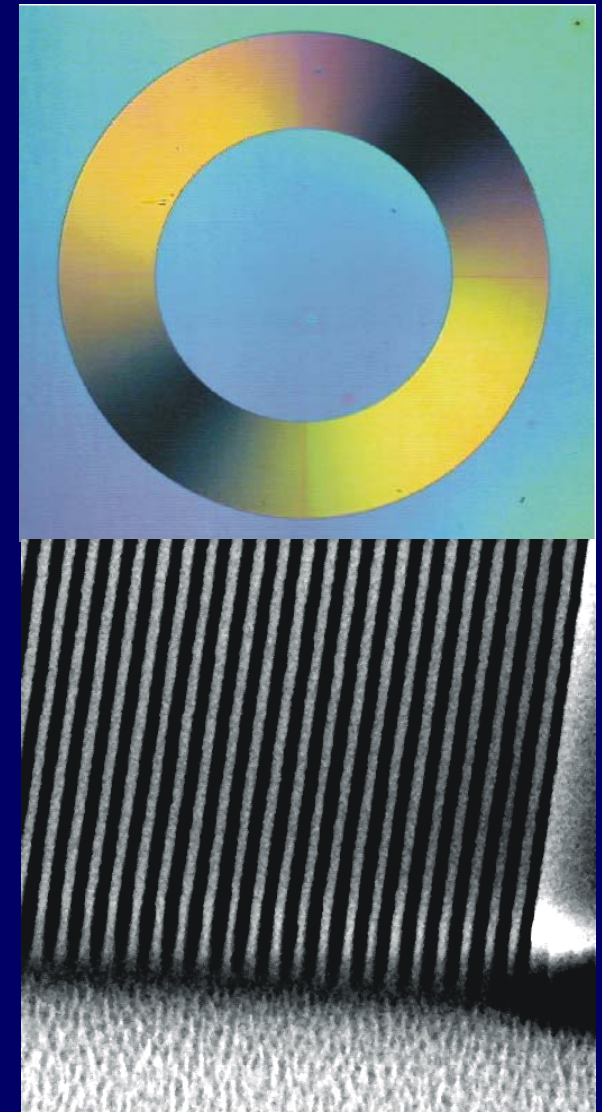
**Summary, Conclusions and Outlook**

# Fresnel zone plates as X-ray lenses



**focal length**  $f = 2 \cdot r_n \cdot dr_n / \lambda$

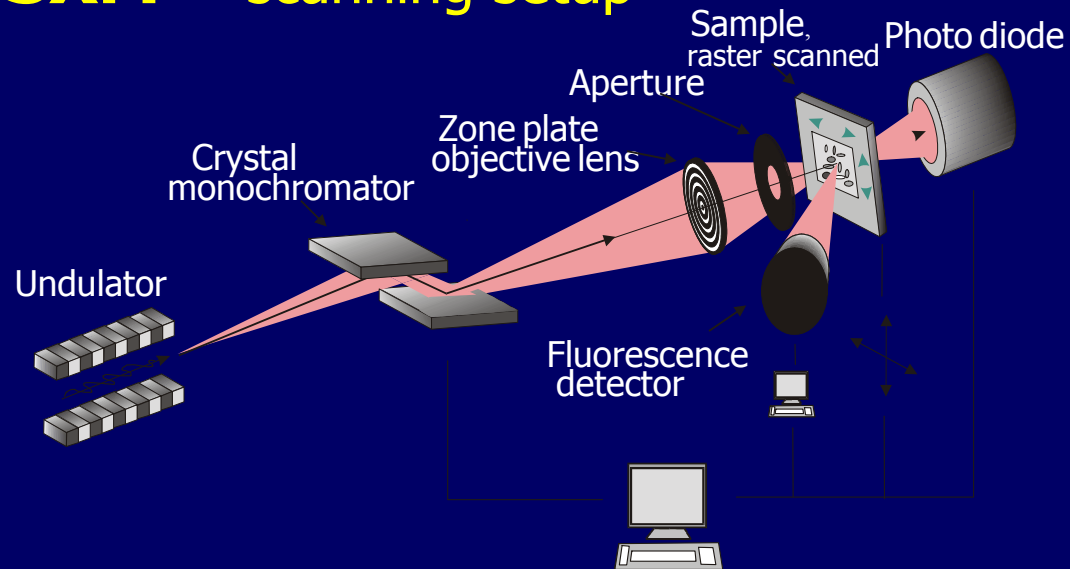
**resolution**  $\delta = 0.61 \cdot \lambda / \text{N.A.}$   
 $\rightarrow \delta = 1.22 \cdot dr_n$



Light microscope image (top) and Scanning electron micrograph (bottom) of a Au Fresnel zone plate, fabricated by D. Hambach (IRP, Universität Göttingen, Germany)

# Zone-plate based X-ray microscopes: two optical schemes

## SXM — scanning setup



### Advantages

- dose efficient
- multiple detection in parallel
- applicable to bulk materials
- easily variable image field size

### Disadvantages

- relatively slow
- sophisticated instrument

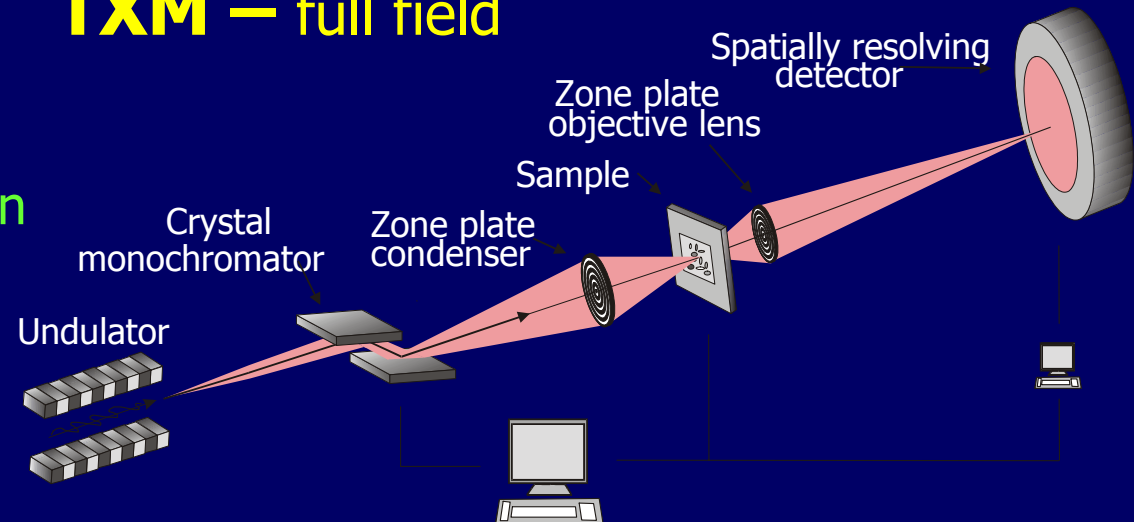
### Advantages

- fast - suitable for tomography
- relatively simple instrumentation
- higher spatial resolution

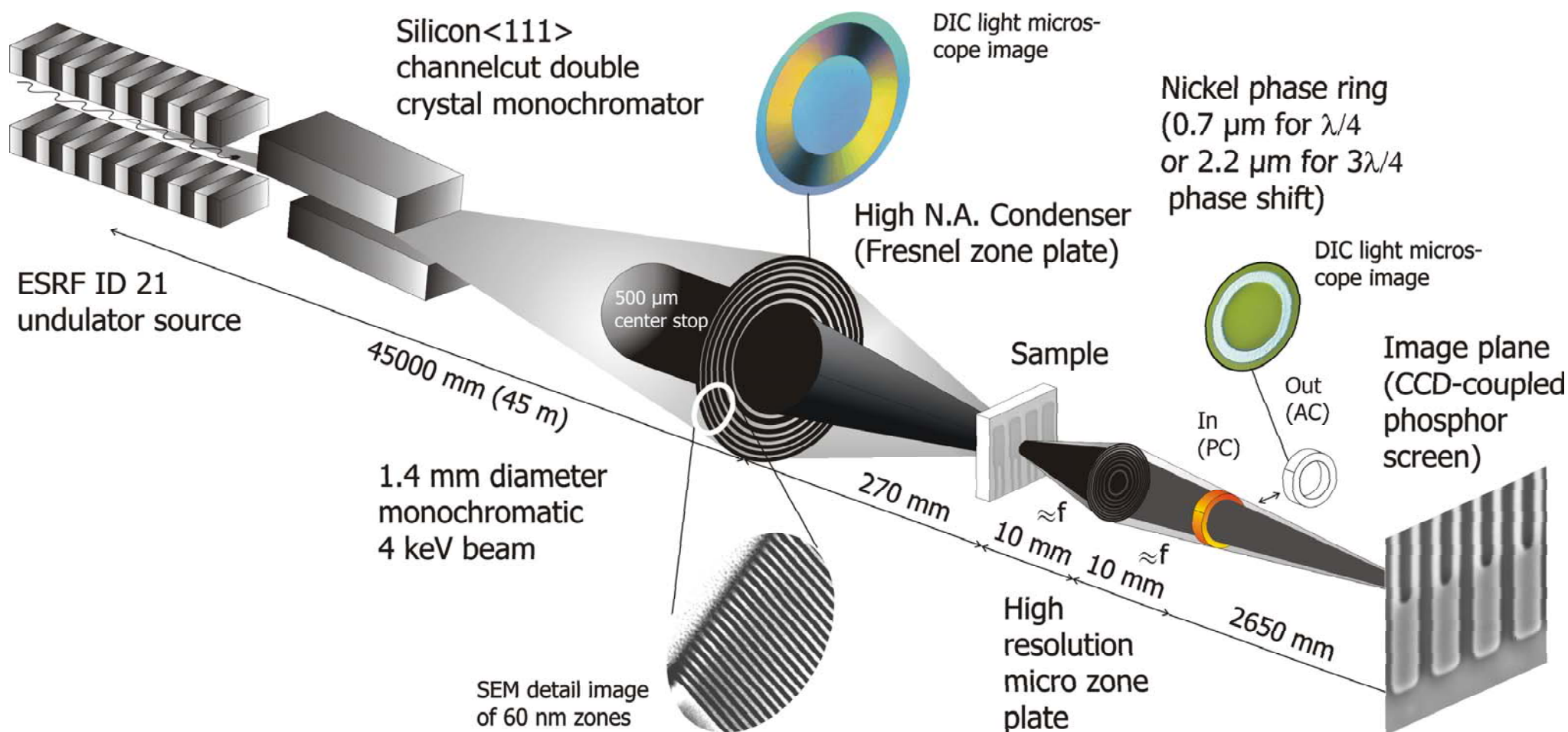
### Disadvantages

- transmission detection only
- dose inefficient

## TXM — full field

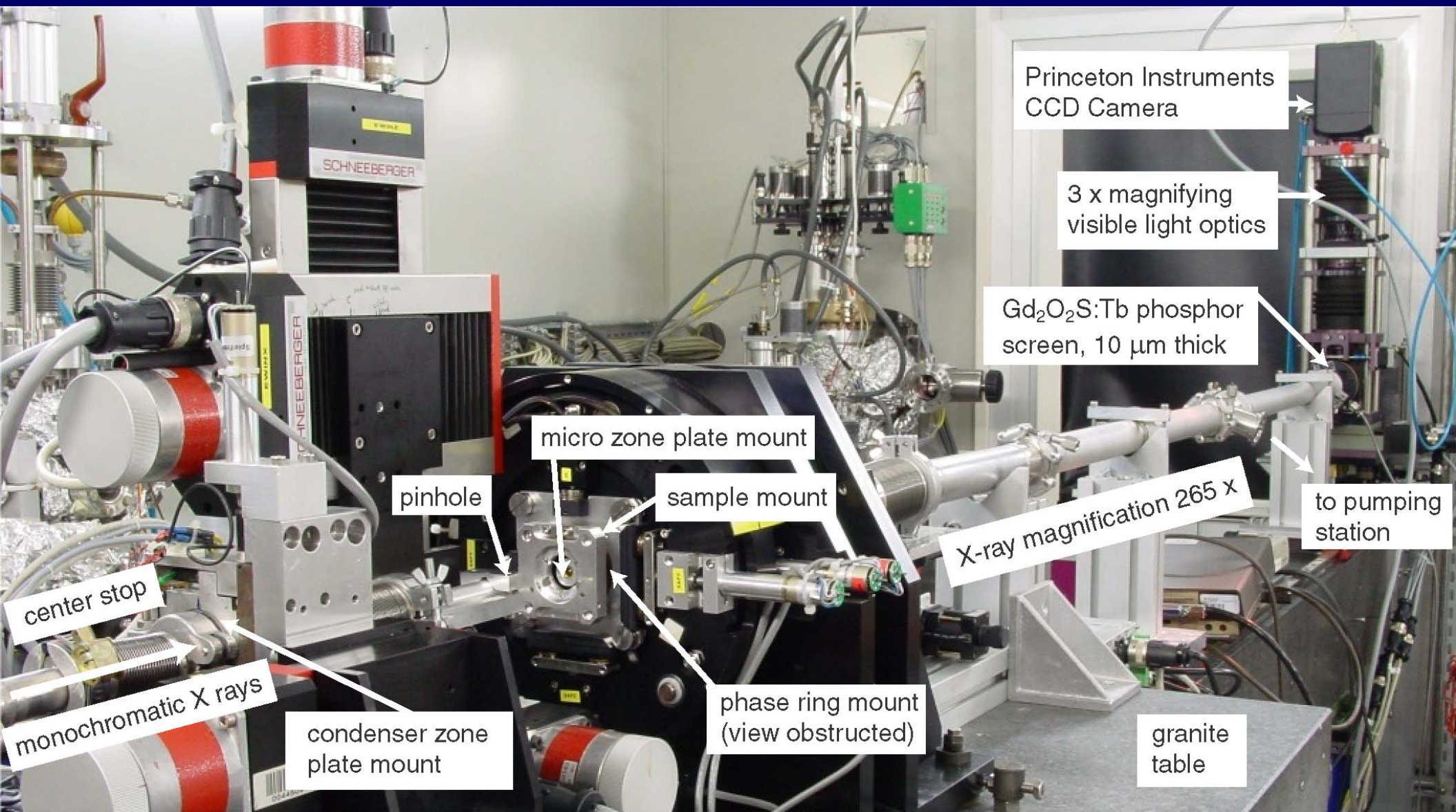


# Zernike Phase contrast: Schematic of the ID 21 TXM setup

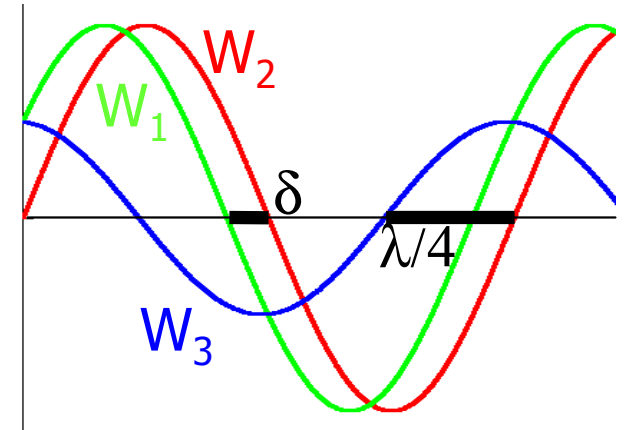
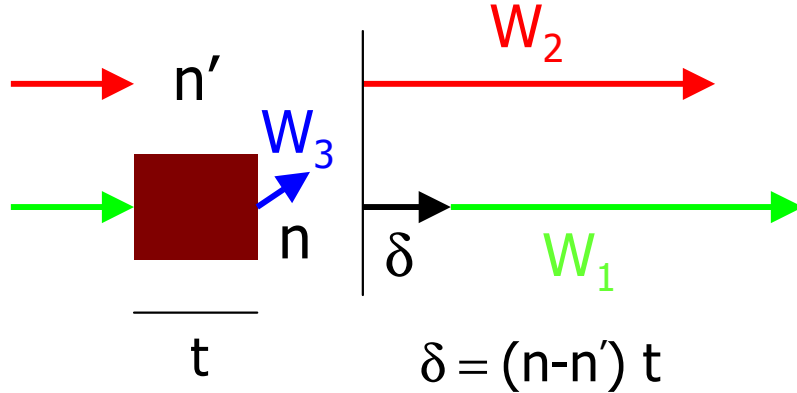




# Photograph of the ID 21 full-field microscope (TXM) endstation setup for Zernike phase contrast imaging



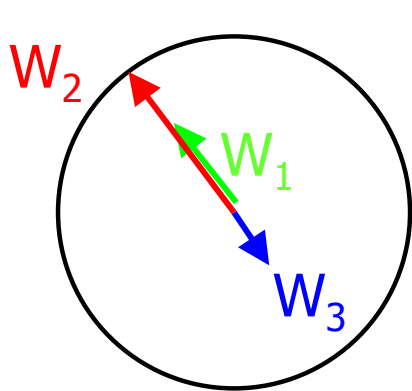
# Zernike Phase contrast - Principle



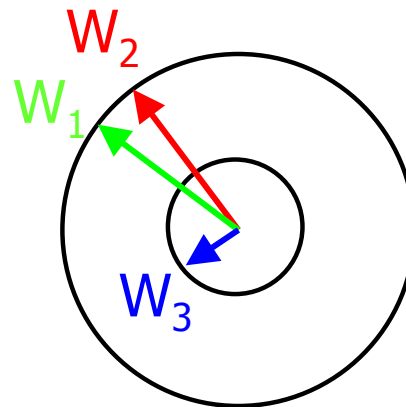
If  $\delta \ll \lambda$ :  $W_1$  can be decomposed as sum of  $W_2$  (direct, undiffracted light) and  $W_3$  (light diffracted from object structures) where  $W_2$  and  $W_3$  are phase shifted by  $\lambda/4$

## How to increase the contrast?

Phase shifting of the undiffracted light  $W_2$  using a phase ring

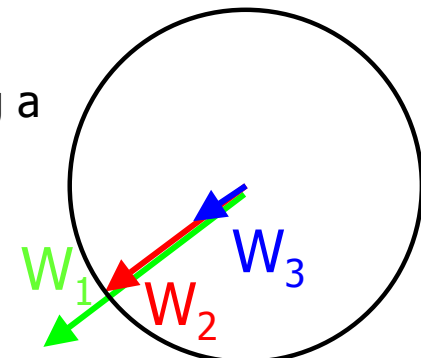


**Amplitude sample:**  
Phase shift of  $\lambda/2$  between direct & diffracted light:  
 $W_1$  significantly smaller than  $W_2 \rightarrow$  good contrast

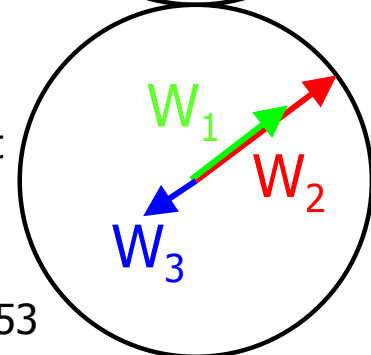


**Phase sample:**  
 $W_1$  has almost the amount as  $W_2 \rightarrow$  weak contrast

**Phase shift  $\lambda/4$ :**  
Positive phase contrast  
Object detail brighter

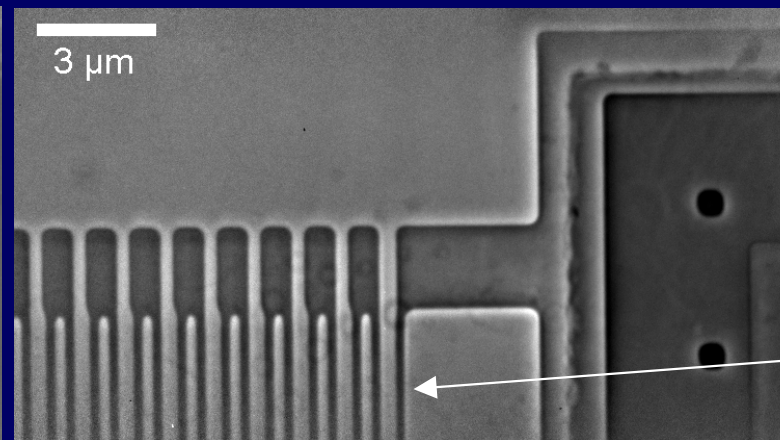
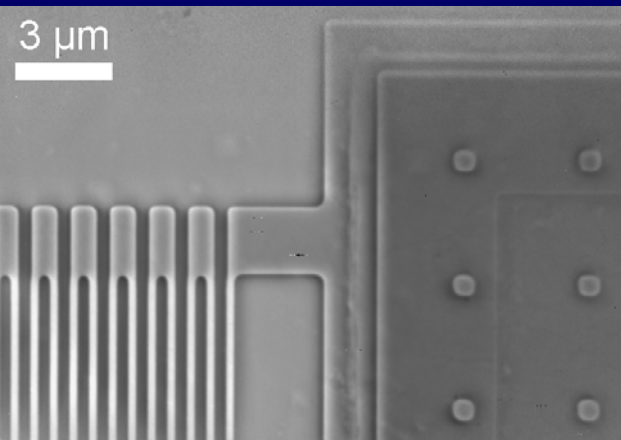


**Phase shift  $3\lambda/4$ :**  
Negative phase contrast  
Object detail darker



F. Zernike  
nobel prize 1953

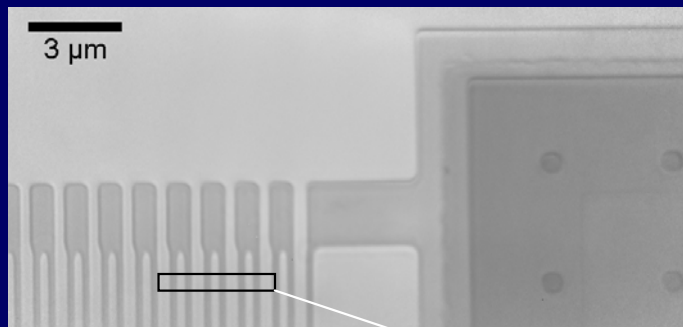
# Phase contrast X-ray microscopy @ 4 keV – Applications I



**SEMATECH-Sample:**  
Copper Interconnects  
within a  $\text{SiO}_2$  dielectric  
in a serpentine resistor,  
smallest line width  
**225 nm**

Positive phase contrast **45 %**  
(0.7  $\mu\text{m}$  high Ni phase ring)

Negative phase contrast **40 %**  
(2.2  $\mu\text{m}$  high Ni phase ring)

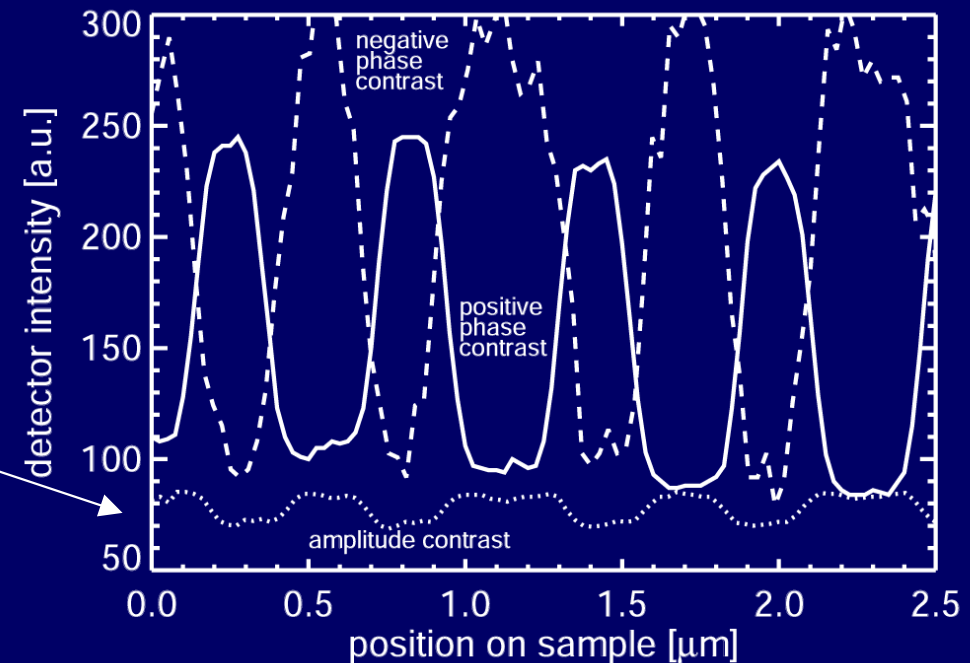


In comparison:

Amplitude contrast **7 %**

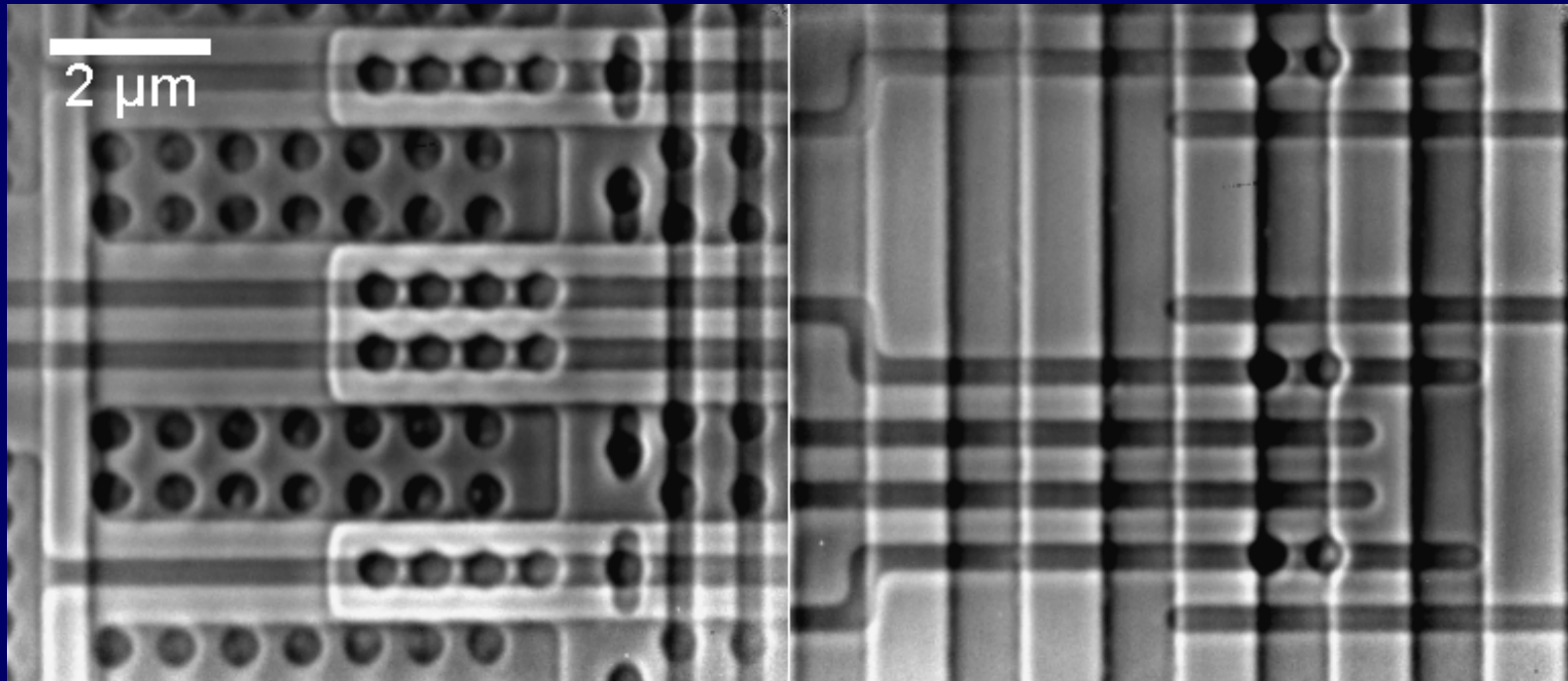
Contrast reversal between:

- Amplitude contrast and positive phase contrast
- positive and negative phase contrast image



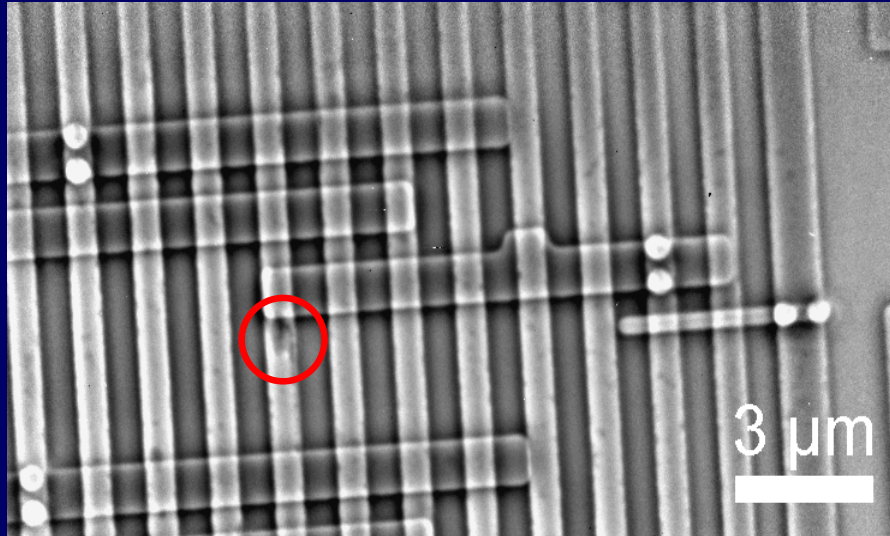


# Zernike Phase contrast @ 4 keV – Applications II



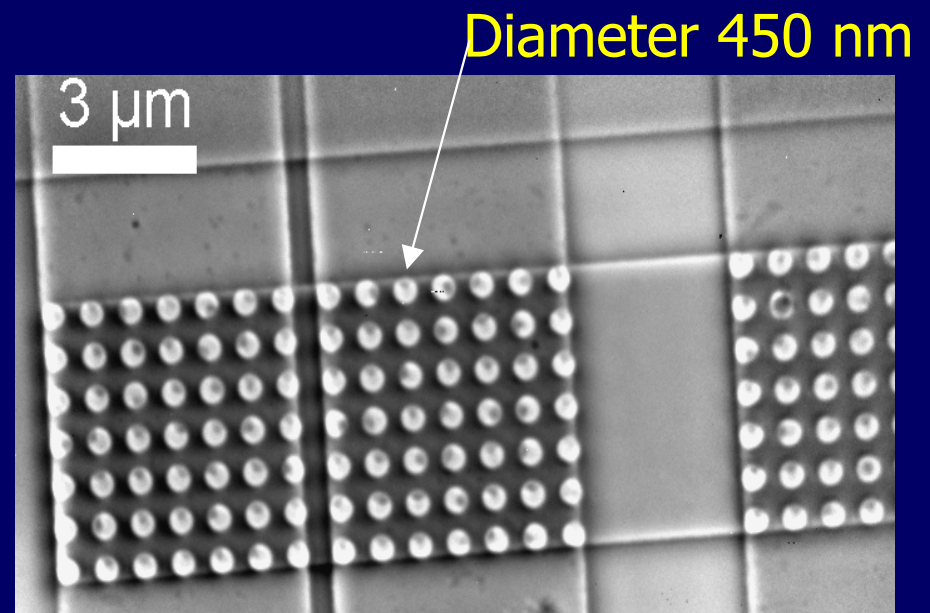
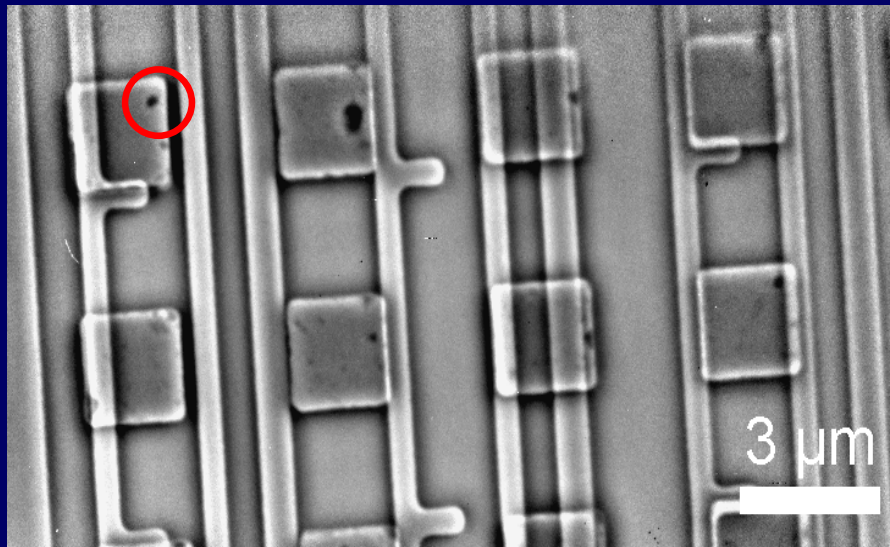
AMD next generation microprozessor:  
Images in negative phase contrast

# Zernike Phase contrast @ 4 keV – Applications III



## AMD-Sample:

Positive phase contrast images  
Studies on defects in a  
microprocessor chip  
Possibility of probing bulk  
material (20  $\mu\text{m}$  thick)



# Conclusions

Full-field X-ray microscope (TXM) using highly coherent undulator radiation:

High numerical aperture (N.A.) Fresnel zone plates with large diameter used as condenser

- provide incoherent or just partially coherent illumination required for full-field X-ray microscopy due to
  - high N.A. that allows use of a center stop to block the highly coherent on-axis 0<sup>th</sup> order beam
  - a diameter larger than the lateral coherence length of the incident radiation at the experimental endstation
- provide matched N.A. illumination for employing high resolution zone plate objectives
- provide sufficient spatial separation of 0<sup>th</sup> and 1<sup>st</sup> diffraction orders so as to allow phase shift manipulation of the 0<sup>th</sup> order (Zernike Phase contrast)

# Summary and Outlook

Full-field X-ray microscope (TXM) in Zernike-type phase contrast mode

Zernike-type Phase contrast microscopy successfully demonstrated close to its theoretically predicted characteristics (resolution, contrast) in the several keV regime (4 keV)

Where to go next?

- Extend the applicability to different kinds of samples (biology, materials science etc.) by choosing matched phase rings
- High-resolution tomography:
  - Assumption of parallel projection for tomography is met
  - micro zone plate depth-of-focus & image field available:  
3D imaging of a sample volume of  $15 \times 15 \times 15 \mu\text{m}^3$  at sub-100 nm resolution feasible